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Early-Transition-Metal Silyl Complexes Free of Anionic π -Ligands. A Comparison of Alkyl and Silyl Ligands*

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A new family of silyl complexes, (RCH₂)₃MSiR'₃ (M = Ti, Zr), (RCH₂)₂Ta(=CHR)SiR'₃ and (RCH₂)₂W(≡CR)SiR'₃, which are free of cyclopentadienyl (Cp) or other supporting anionic π -ligands, have been prepared and characterized. The silyl ligands are found to be more reactive than the alkyl ligands in the silyl alkyl and silyl alkylidene complexes. Silane (HSiR'₃) elimination to form metal-carbon multiple bonds is preferred over alkane (RCH₃) elimination. In the formation of (Me₃SiCH₂)₂Ta(=CHSiMe₃)Si(SiMe₃)₃ from the reaction of (Me₃SiCH₂)₃TaCl₂ with 2 equiv of Li(THF)₃Si(SiMe₃)₃, an intermediate (Me₃SiCH₂)₃Ta(Cl)Si(SiMe₃)₃ was identified. The first step in the conversion of this intermediate to (Me₃SiCH₂)₂Ta(=CHSiMe₃)Si(SiMe₃)₃ is a silane [HSi(SiMe₃)₃] elimination reaction to form "(Me₃SiCH₂)₂Ta(=CHSiMe₃)Cl". The dimer of "(Me₃SiCH₂)₂Ta(=CHSiMe₃)Cl", (Me₃SiCH₂)₄(Cl)₂Ta₂(=CHSiMe₃)₂, was observed in the formation of (Me₃SiCH₂)₂Ta(=CHSiMe₃)Si(SiMe₃)₃ and in the decomposition of (Me₃SiCH₂)₃Ta(Cl)Si(SiMe₃)₃. Subsequent Cl⁻ substitution by Si(SiMe₃)₃⁻ leads to the formation of the silyl alkylidene complex. In comparison, the first step in the reaction of (RCH₂)₄TaCl (R = CMe₃, SiMe₃) with LiCH₂R to form alkyl alkylidene complexes (RCH₂)₃Ta=CHR is Cl⁻ substitution by CH₂R⁻ to form Ta(CH₂R)₅. Subsequent alkane

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^{*}Dedicated to Professor Herbert D. Kaesz, a scientist, mentor and friend.

elimination gives (RCH₂)₃Ta=CHR. The kinetic and mechanistic studies of these processes will be discussed.

Key Words: silyl complexes, early transition metals, alkyl, alkylidene, alkylidyne complexes, α-hydrogen abstraction

INTRODUCTION

Transition-metal silyl chemistry has been a subject of intense study for four decades, since the report in 1956 of the preparation of (η^{5} -Cp)(CO)₂FeSiMe₃ (Cp = cyclopentadienyl) by Wilkinson and co-workers, the first compound known to contain a transition metal-silicon bond.1 The family of transition-metal silyl compounds now includes almost all of the transition elements.² The large majority of these silyl complexes are those of late-transition-metal elements; many coordinatively saturated, electron-rich transition-metal silyl complexes are quite stable. The chemistry of electron-poor early-transition-metal silyl compounds is, however, comparatively young.² The studies in this area have been focused mostly on silyl compounds supported by Cp or analogous anionic π -ligands; the work of many researchers has laid a solid foundation in this area.2a,3 The presence of such ligands in, e.g., $Cp_2Zr(SiR_3)R'$, $^{4a}Cp_2Ta(=CH_2)SiH^tBu_2^{4b}$ and $Cp_2W(\eta^2-Me_2Si=SiMe_2)$, 4c is believed to contribute to the enhanced stabilities of these silyl compounds. The few known Cp-free early-transition-metal silyl complexes, such as $V(CO)_6SiH_3$, $^5(Me_3CO)_3MSi(SiMe_3)_3(M = Zr, Hf)^6$ and $(Me_3P)_3$ W(H)₂I(SiMe₃),⁷ usually contain carbonyls, alkoxides or phosphines as ancillary ligands.8

We began studying the following new family of Cp-free early-transition-metal silyl complexes (Scheme 1) in 1993. Our initial interest in these alkyl, alkylidene and alkylidyne silyl complexes originated from our proposal to investigate the reactions between silane SiH₄ and M(CH₂R)₄, (RCH₂)₃M=CHR, or (RCH₂)₃M≡CR, and the chemistry involved in these processes. The novel silyl complexes in Scheme 1 were proposed as models for the possible intermediates in these reactions. Realizing that these complexes offered unique opportunities to compare the reactivities of alkyl and silyl ligands free of the influence of Cp or other ancillary ligands, we subsequently concentrated our efforts in this area. The aim of this *Comment* is to discuss: (1) the synthesis, characterization and structural features of these Cp-free silyl complexes; (2) a comparison, through kinetic and mechanistic studies, of the formation of M=CHR bonds in a

SiR'3 SiR'3 SiR'3 SiR'3

RCH2'
$$\stackrel{M}{/}$$
 CH2R RCH2' $\stackrel{T}{/}$ CHR RCH2' $\stackrel{M}{/}$ CR RCH2 RCH2 RCH2

(M = Ti, Zr)

silyl alkylidene complex (Me₃SiCH₂)₂Ta(=CHSiMe₃)Si(SiMe₃)₃ and in alkyl alkylidene complexes (RCH₂)₃Ta=CHR (R = CMe₃, SiMe₃).

Cp-FREE SILYL COMPLEXES AND THE REACTIONS OF SiH₄ WITH ALKYL, ALKYLIDENE AND ALKYLIDYNE COMPOUNDS

Our preliminary results show that silane SiH₄ reacts with Ti(CH₂CMe₃)₄, (Me₃CCH₂)₃Ta=CHCMe₃, or (Me₃CCH₂)₃W≡CCMe₃; the gaseous product is neopentane CMe₄.⁹ We have been studying these σ-bond metathesis reactions to explore novel molecular routes to metal silicides MSi_n, an important class of microelectronic, high-temperature and IR detector materials.¹⁰

Alkyl ligands in metallocenes Cp_2MR_2 (M = Ti triad) and $TiMe_2(dmpe)_2$ have been found to undergo, among other processes, similar σ -bond metathesis with silanes $H_xSiR'_{4-x}$ (Eq. (1)).^{3a,11,12}

$$M'-R+H-Si \rightarrow M'-Si+H-R$$

$$[M'=Cp_2MR-and (dmpe)_2 TiMe]$$
(1)

It would be of interest to study how such metathesis would occur in our proposed reactions of $M(CH_2R)_4$, $(RCH_2)_3M=CHR$, or $(RCH_2)_3M=CR$ with SiH_4 , where all the $M-CH_2R$, M=CHR and M=CR bonds are expected to react with the Si-H bonds. In the reaction between $M(CH_2R)_4$ and SiH_4 , the first step in the reaction might give $(RCH_2)_3M-SiH_3$. Then there are several possible routes by which this intermediate could further react. The proposed reactions are shown in Scheme 2. $(RCH_2)_3M-SiH_3$ could react with another SiH_4 (Route 1) to form $(RCH_2)_2M(SiH_3)_2$ (Si/M ratio = 2) and eventually silicon-rich MSi_n ($n \ge 2$). It could also go through intramolecular σ -bond metathesis (Route 2) to form $(RCH_2)_2M=SiH_2$ or, more likely, a dimer

$$(RCH_2)_4M + SiH_4 \xrightarrow{-RCH_3} (RCH_2)_3M - SiH_3 \xrightarrow{ROute\ 1} (RCH_2)_4M (SiH_3)_2 \xrightarrow{-} MSi_n$$

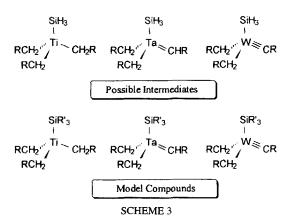
$$(RCH_2)_4M + SiH_4 \xrightarrow{-RCH_3} (RCH_2)_3M - SiH_3 \xrightarrow{ROute\ 2} -RCH_3 \xrightarrow{1/2} (RCH_2)_4M_2(\mu - SiH_2)_2 \xrightarrow{-} MSi_n$$

$$SCHEME\ 2$$

 $(RCH_2)_4M_2(\mu-SiH_2)_2$. Route 2 may lead to MSi which retains M/Si = 1 as in $(RCH_2)_3M-SiH_3$. A key question is what factors control the reactivities of the intermediate $(RCH_2)_3M-SiH_3$.

In the reactions of $(RCH_2)_3M=CHR$ or $(RCH_2)_3M=CR$ with SiH_4 , similar pathways may exist with $(RCH_2)_2M(=CHR)SiH_3$ or $(RCH_2)_2M(=CHR)SiH_3$ as the possible intermediates.

We proposed to use (RCH₂)₃MSiR'₃, (RCH₂)₂M(=CHR)SiR'₃ and (RCH₂)₂M(≡CR)SiR'₃ (R' = H, alkyl) as models for the possible intermediates (Scheme 3). Besides the potential relevance of these model compounds to the possible intermediates, we were also interested in the chemistry of these model compounds since, except for a few silyl complexes with CO, alkoxides, or phosphine ligands, chemistry of Cp-free early-transition-metal silyl complexes was an unexplored area. With such a two-fold interest, we started the first step—preparation of these novel Cp-free silyl complexes.



2. SYNTHESES AND CHARACTERIZATION

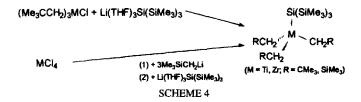
The primary method that we used to prepare these Cp-free silyl complexes was the substitution of a halide ligand such as Cl⁻ by a silyl anion SiR'₃⁻.

2.1 Alkyl Silyl Compounds $(RCH_2)_3M$ –Si $(SiMe_3)_3$ $(M = Ti, Zr; R = CMe_3, SiMe_3)$ (Refs. 13 and 14)

The reactions used to synthesize these compounds are shown in Scheme 4. They are almost instantaneous at 23°C with the precipitation of LiCl.¹⁵ These compounds are thermally stable in crystalline form, showing little or no degradation over several days in the dark at room temperature. The Zr complexes are significantly more stable than the Ti analogues. (Me₃CCH₂)₃Zr-Si(SiMe₃)₃ could be sublimed in darkness at 40°C without significant decomposition.

The two titanium complexes (RCH₂)₃Ti-Si(SiMe₃)₃ (R = CMe₃, SiMe₃) were characterized by X-ray diffraction; the molecular structure of the trimethylsilylmethyl compound is shown in Fig. 1. The crystal structures reveal threefold symmetry axes along the Ti-Si bonds with the alkyl groups on the metal center in staggered conformations with respect to the trimethylsilyl groups on the central silicon atom. The three alkyl and the silyl ligands present a pseudo-tetrahedral geometry around the metal centers. The coordination about the α-carbon atoms is greatly distorted from tetrahedral [Ti-C-C angle of 141.7(12)° (mean) in (Me₃CCH₂)₃Ti-Si(SiMe₃)₃ and Ti-C-Si angle of 130.4(4)° in (Me₃SiCH₂)₃Ti-Si(SiMe₃)₃]. No evidence of an agostic interaction was seen in their variable-temperature NMR spectra. The widening of the Ti-C-C (or Si) bond angles is probably caused by steric strain.

In comparison, the crystal structure of the similarly arranged alkoxy/silyl zirconium compound (Me₃CO)₃ZrSi(SiMe₃)₃6 shows a mean O–Zr–O angle of 111.4(4)° and a mean O–Zr–Si angle of 107.6(3)°. The



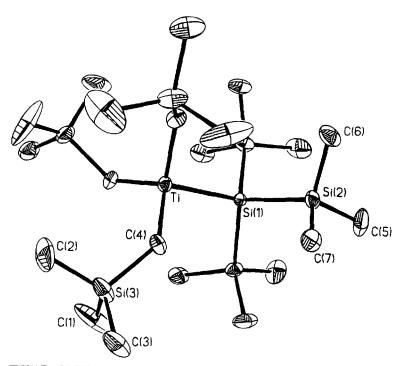


FIGURE 1 ORTEP diagram of (Me₃SiCH₂)₃Ti-Si(SiMe₃)₃ (Ref. 14).

Zr-O-C angle in the alkoxy complex $[165(1)^{\circ}]$ is larger than the mean Ti-C-C angle in $(Me_3CCH_2)_3Ti-Si(SiMe_3)_3$ and Ti-C-Si angle in $(Me_3SiCH_2)_3Ti-Si(SiMe_3)_3$, and is consistent with the assumption of some degree of $O(p\pi)-Zr(d\pi)$ bonding in $(Me_3CO)_3ZrSi(SiMe_3)_3$.6

2.2 Alkylidene Silyl Compound (RCH₂)₂Ta(=CHR)SiR'₃ (Refs. 13 and 16)

The reactions used to synthesize these Schrock-type alkylidene compounds¹⁷ are shown in Eq. (2).

$$(RCH_2)_3 TaCl_2 + 2Li(THF)_3 SiR'_3 \xrightarrow{\text{Hexanes}} RCH_2 \xrightarrow{\text{Ta}} CHR + HSiR'_3$$

$$[R = Me_3C, Me_3Si; R'_3 = (SiMe_3)_3, Ph_2^!Bu]$$

$$RCH_2 \xrightarrow{\text{CHR}} Ta = CHR + HSiR'_3$$

The lithium silvlating reagent Li(THF)₃SiR'₃ (2 equiv) reacts instantaneously with 1 equiv of the trialkyl tantalum dichloride to form the alkylidene silvl compounds and 1 equiv of the corresponding silane HSiR'₃ in high yield. α-Hydrogen abstraction reactions between the silyl groups and alkyl ligands led to the formation of the alkylidene bonds. The two complexes with SiPh₂'Bu ligands, (Me₃CCH₂)₂Ta(=CHCMe₃)SiPh₂'Bu and (Me₃SiCH₂)₂Ta(=CHSiMe₃)SiPh₂^tBu, were found to be unstable at 23°C; the latter undergoes α-hydrogen abstraction between the silvl group and the alkylidene ligand to form $(Me_3SiCH_2)_4Ta_2(\mu-CSiMe_3)_2$, a bridging bis(alkylidyne) complex first reported by Wilkinson and co-workers¹⁸ (Scheme 5). However, when phosphine (PMe₃) was added to (Me₃SiCH₂)₂Ta(=CHSiMe₃)SiPh₂^tBu, a phosphine adduct was formed; its NMR spectra are consistent with a formula (Me₃SiCH₂)(Me₃SiCH=)₂Ta(PMe₃)₂ with two alkylidene ligands.¹⁹ It was perhaps formed through α-hydrogen abstraction between the silyl ligand and a hydrogen atom of one alkyl ligand. It may also be the product of the reaction between "(Me₃SiCH₂)₂(Me₃SiC≡)Ta" and PMe₃ with α -hydrogen transfers. In the absence of PMe₃, "(Me₃SiCH₂)₂(Me₃SiC \equiv)Ta" perhaps dimerizes to give the bridging bis(alkylidyne) complex.

There are large chemical shift differences between the diastereotopic H_a and H_b atoms of the RCH_aH_b groups in ¹H NMR [1.96 ppm for (Me₃CCH₂)₂Ta(=CHCMe₃)Si(SiMe₃)₃ and 1.15 ppm for (Me₃SiCH₂)₂Ta(=CHSiMe₃)Si(SiMe₃)₃]. No evidence in favor of agostic interaction was seen in the variable-temperature ¹H or ¹³C NMR of the complexes. It appears that the chemical shift differences are due to the diamagnetic anisotropy of the Ta=C bonds.

The molecular structures of $(RCH_2)_2Ta(=CHR)Si(SiMe_3)_3$ $(R = CMe_3)_2Ta(=CHR)Si(SiMe_3)_3$ SiMe₃) have been determined; the structure of the trimethylsilylmethyl complex is shown in Fig. 2. Crystallographically imposed threefold rotation axes containing the Si-Ta bonds in both complexes result in disorders between the alkylidene and the two alkyl ligands. The Ta-C bond lengths are 1.97(3) and 2.03(4) Å, respectively, in the two complexes. In comparison, the Ta-C and Ta=C bond length are 2.285(10)-2.299(10) and 1.932(9)-1.937(9) Å in $[Ta(=CHCMe_3)(PMe_3)_2]_2(\mu-N_2)^{20}$ and 2.17(2) and 1.89(3) Å in $Ta(=CHSiMe_3)(CH_2SiMe_3)(OC_6H_3^4Bu_2-2.6)_2.^{21}$ In both silyl complexes, the -Si(SiMe₃)₃ and the alkyl(alkylidene)-Ta moieties are arranged in a staggered conformation which is similar to those observed in (RCH₂)₃TiSi(SiMe₃)₃ (R = CMe₃ and SiMe₃) and (Me₃CO)₃ZrSi(SiMe₃)₃.6 The Ta-Si distances of 2.680(15) and 2.611(7) Å in the two silyl complexes compare favorably with the Ta-Si distances of 2.624(2)-2.633(2) Å in $Cp_2Ta(H)(SiMe_2H)_2$, 22 2.669(4) Å in (C₅Me₅)Ta(SiMe₃)Cl₃,²³ and 2.651(4) Å in Cp₂Ta(H)₂SiPhMe₂.²⁴

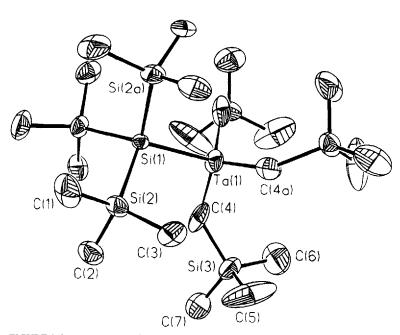


FIGURE 2 ORTEP diagram of (Me₃SiCH₂)₂Ta(=CHSiMe₃)Si(SiMe₃)₃ (Refs. 13 and 16).

 $(RCH_2)_2Ta(=CHR)Si(SiMe_3)_3$ (R = CMe₃ and SiMe₃) were found to react with 1 equiv of HCl at -78°C to form unstable purple complexes $(RCH_2)_3Ta(Cl)Si(SiMe_3)_3$ (Eq.(3)).

$$(RCH2)2Ta (=CHR)Si (SiMe3)3 + HCl \rightarrow (RCH2)3Ta(Cl)Si (SiMe3)3(R = CMe3, SiMe3)$$
(3)

When (Me₃SiCH₂)₂TaCl₂ reacted with Li(THF)₃Si(SiMe₃)₃ at -78°C, the purple complex (Me₃SiCH₂)₃Ta(Cl)Si(SiMe₃)₃ was observed. The reactions of the purple complex with Li(THF)₃Si(SiMe₃)₃ and LiCH₂SiMe₃ form (Me₃SiCH₂)₂Ta(=CHSiMe₃)Si(SiMe₃)₃ and (Me₃SiCH₂)₃Ta=CHSiMe₃, ^{17d,25} respectively. Detailed kinetic and mechanistic studies will be presented in Section 3.

2.3 Alkylidyne Silyl Compound (Me₃CCH₂)₂W(≡CCMe₃)Si(SiMe₃)₃ (Ref 13)

This first silyl alkylidyne compound, a model for $(RCH_2)_2W(\equiv CR)SiH_3$, was prepared by the reactions shown in Scheme 6. The starting Schrock-type alkylidyne complex²⁶ contains a $W\equiv CCMe_3$ moiety, which is retained during synthesis. In comparison, the Ta=CHR bonds are formed through α -hydrogen abstraction during the formation of the alkylidene silyl complexes. There is a large chemical shift difference (4.56 ppm) between the diastereotopic H_a and H_b atoms of the RCH_aH_b groups in ¹H NMR as a result of the diamagnetic anisotropy of the $W\equiv C$ bond.

In our studies of (Me₃SiCH₂)₃W≡CSiMe₃ and our attempt to prepare "(Me₃SiCH₂)₂W(≡CSiMe₃)Si(SiMe₃)₃" by reactions similar to those in Scheme 6, we were surprised by the difference in reactivity between (Me₃SiCH₂)₃W≡CSiMe₃ and the neopentyl analog (Me₃CCH₂)₃W≡CCMe₃.²⁶ The reaction of (Me₃SiCH₂)₃W≡CSiMe₃ with HCl does *not* lead to the elimination of SiMe₄ and our target compound "(Me₃SiCH₂)₂W(≡CSiMe₃)Cl". Instead, the reaction, through an addition of HCl to the W≡CSiMe₃ bond, produces a thermally unstable alkylidene

$$\begin{array}{c|c} CH_2R & CI & Si(SiMe_3)_3 \\ \hline RCH_2 & W & CR \\ RCH_2 & RCH_2 & RCH_2 \\ \hline RCH_2 & RCH_2 & RCH_2 \\ \hline \end{array}$$

compound with a formula consistent with (Me₃SiCH₂)₃W(=CHSiMe₃)Cl from its NMR spectra. The addition of Li(THF)₃Si(SiMe₃)₃ or LiCH₂SiMe₃ to this alkylidene compound gives (Me₃SiCH₂)₃W=CSiMe₃ back with the elimination of HSi(SiMe₃)₃ or SiMe₄. It is not clear if Si(SiMe₃)₃ directly attacks the alkylidene hydrogen atom or replaces the Cl⁻ ligand first before undergoing α-hydrogen abstraction to form the W=CSiMe₃ bond. In the reaction of HCl with (Me₃SiCH₂)₃W=CSiMe₃ in the presence of PMe₃, an alkylidyne product was isolated, which has been tentatively assigned to be (Me₃SiCH₂)₂W(=CSiMe₃)(Cl)(PMe₃). However, the reaction of this chloro alkylidyne compound with Li(THF)₃Si(SiMe₃)₃ does not lead to the replacement of the chloride ligand. Some unknown products form in the process. The reactions of (Me₃SiCH₂)₃W=CSiMe₃ discussed here are summarized in Scheme 7.

3. SILANE AND ALKANE ELIMINATION—A COMPARISON OF REACTIVITIES OF SILYL AND ALKYL LIGANDS IN THE FORMATION OF ALKYLIDENE BONDS

3.1 Preferential Silane Elimination in α -Hydrogen Abstraction Reactions

It is interesting to note that, in the quantitative formation of $(RCH_2)_2Ta(=CHR)SiR_3$ (Eq. (2)), there is an unprecedented *preferential* silane $[HSi(SiMe_3)_3]$ elimination through α -hydrogen abstraction to give the silyl alkylidene complex. Similar preferential silane eliminations have also been observed in other reactions summarized in Scheme 8. The unsta-

$$(RCH_2)_3W \equiv CR$$

$$(R = SiMe_3)$$

$$+ Li(THF)_3SiR_3$$

$$or LiCH_2R$$

$$| + PMe_3 |$$

$$(RCH_2)_3W \equiv CR$$

$$| PMe_3 |$$

$$+ HCI$$

$$(RCH_2)_2W \equiv CR$$

$$| PMe_3 |$$

$$SCHEME 7$$

$$(RCH_2)_2 Ta \overset{CH_2R}{\sim} -RCH_3 - (RCH_2)_2 Ta \overset{C}{\sim} Ta(CH_2R)_2$$

$$+ LiCH_2R \overset{1}{\rightarrow} -HSiR_3 - RCH_2$$

$$(RCH_2)_3 TaCl_2 \overset{+ Li(THF)_3 SiR_3}{\sim} -RCH_2$$

$$(RCH_2)_3 TaCl_2 \overset{+ Li(THF)_3 SiR_3}{\sim} -RCH_2$$

$$(RCH_2)_4 (CI)_2 Ta_2 (=CHR)_2 \overset{- RCH_3}{\sim} -(RCH_2)_3 (CI)_2 Ta_2 (=CHR) (=CR)$$

$$SCHEME 8$$

ble deep purple alkyl silyl intermediate (Me₃SiCH₂)₃Ta(Cl)Si(SiMe₃)₃ undergoes silane elimination in its reaction with LiCH2SiMe2 to form a Schrock-type alkyl alkylidene complex (Me₃SiCH₂)₃Ta=CHSiMe₃. Subsequent alkane elimination (to be discussed in Section 3.3) converts (Me₃SiCH₂)₃Ta=CHSiMe₃ into the bridging alkylidyne compound (Me₃SiCH₂)₄Ta₂(μ-CSiMe₃)₂. ¹⁸ In the presence of Li(THF)₃Si(SiMe₃)₃, the alkyl silyl intermediate (Me₃SiCH₂)₃Ta(Cl)Si(SiMe₃)₃ is converted to the silyl alkylidene complex (Me₃SiCH₂)₂Ta(=CHSiMe₃)Si(SiMe₃)₃. (Me₃SiCH₂)₃Ta(Cl)Si(SiMe₃)₃ decomposes, through silane elimination. form unstable bis(alkylidene) an $(Me_3 SiCH_2)_4(Cl)_2Ta_2(=CHSiMe_3)_2$. This silane elimination is then followed by alkane elimination to form an alkylidene alkylidyne complex $(Me_3SiCH_2)_3(Cl)_2Ta_2(=CHSiMe_3)(=CSiMe_3).$

The reason for such preferential silane elimination is not clear. Experimental and theoretical studies of Si–X and C–X bond strengths reveal that the substituents with electronegativities closer to silicon tend to form stronger bonds to carbon than to silicon, due to higher ionic character in the C–X bonds.²⁷ If this principle applies to Si–Ta and C–Ta bond strengths, an analysis of electronegativities (Ta: 1.50; Si: 1.90; C: 2.55)²⁸ indicates that the Ta–C bonds are more polar and stronger than Ta–Si bonds. However, our *ab initio* quantum mechanics calculations²⁹ of the reactivities of MCl_x(CH₃)_y(SiH₃)_z (M = Nb, Ta) show that CH₄ elimination is usually thermodynamically more favorable than SiH₄ elimination. The weaker M–Si bond in MCl_x(CH₃)_y(SiH₃)_z may not be

the reason for the preference for silane elimination. Such preference could be attributed to a kinetic effect; the calculated activation free energy is lower for silane elimination than for methane elimination by about 4–5 kcal/mol.²⁹

3.2 Kinetic and Mechanistic Studies of the Formation of a Silyl Alkylidene Complex (Me₃SiCH₂)₂Ta(=CHSiMe₃)Si(SiMe₃)₃ (Ref. 16)

The principal difference between the structures of $(Me_3SiCH_2)_3Ta = CHSiMe_3$ and $(Me_3SiCH_2)_2Ta (= CHSiMe_3)Si(SiMe_3)_3$ is that the former contains three alkyl ligands and the latter is composed of two alkyl and one silyl ligands. These two complexes make an ideal case to compare the differences in reactivities between alkyl and silyl ligands.

The pioneering work of Schrock and others has laid solid foundations in the areas of alkylidene and alkylidyne complexes.^{17,26} The discovery of a purple intermediate (Me₃SiCH₂)₃Ta(Cl)Si(SiMe₃)₃ in the formation of (Me₃SiCH₂)₂Ta(=CHSiMe₃)Si(SiMe₃)₃ prompted us to investigate the mechanistic pathways to the silyl alkylidene complex. We also studied the mechanistic pathways to alkyl alkylidene complexes (RCH₂)₃Ta=CHR (R = CMe₃, SiMe₃).³⁰ We were surprised by the different pathways (Me₃SiCH₂)₃Ta(Cl)Si(SiMe₃)₃ and (RCH₂)₄TaCl followed to form (Me₃SiCH₂)₂Ta(=CHSiMe₃)Si(SiMe₃)₃ and (RCH₂)₃Ta=CHR, respectively. Discussed below are the results of these studies and a comparison of reactivities of alkyl and silyl ligands.

Two possible pathways for the reactions of (RCH₂)₃Ta(Cl)ER'₃ [ER'₃ = CH₂R, Si(SiMe₃)₃, R = CMe₃, SiMe₃] with LiER'₃ to form (RCH₂)₂Ta(=CHR)ER'₃ are listed in Scheme 9. Such pathways have been postulated for the reaction of (Me₃CCH₂)₃TaCl₂ with LiCH₂CMe₃

$$(RCH_{2})_{3}TaCl_{2} \xrightarrow{+\text{LiER'}_{3}} (RCH_{2})_{3}Ta \xrightarrow{CI} \xrightarrow{-\text{HER'}_{3}} \left[(RCH_{2})_{2}Ta \xrightarrow{CI} \xrightarrow{CHR} \right]$$

$$+\text{LiER'}_{3} \left[Route 2 \xrightarrow{\text{ER'}_{3}} \xrightarrow{-\text{HER'}_{3}} (RCH_{2})_{2}Ta \xrightarrow{\text{ER'}_{3}} \xrightarrow{\text{CHR}} \right]$$

$$[RCH_{2})_{3}Ta \xrightarrow{\text{ER'}_{3}} \xrightarrow{-\text{HER'}_{3}} (RCH_{2})_{2}Ta \xrightarrow{\text{CHR}} \xrightarrow{\text{CHR}} (RCH_{2})_{2}Ta \xrightarrow{\text{CHR}} \xrightarrow{\text{CHR}} (RCH_{2})_{2}Ta \xrightarrow{\text{CH$$

to form $(Me_3CCH_2)_3Ta=CHCMe_3$. To Currently there is no firm conclusion in the literature regarding the mechanisms of the formation of $(RCH_2)_2Ta(=CHR)ER'_3$. In Route 1, the first step is an α -hydrogen abstraction reaction by the ER'_3 ligand to eliminate HER'_3 and form an intermediate " $(RCH_2)_2Ta(=CHR)Cl$ " containing an alkylidene bond. Subsequent Cl substitution by ER'_3 leads to the formation of the alkyl alkylidene or silyl alkylidene complex $(RCH_2)_2Ta(=CHR)ER'_3$. In other words, the alkylidene bond forms before the Cl substitution in Route 1. In Route 2, the first step is the Cl substitution to form a penta-coordinated $(RCH_2)_3Ta(ER'_3)_2$, followed by an α -hydrogen abstraction reaction to form $(RCH_2)_2Ta(=CHR)ER'_3$. The alkylidene bond is formed after the Cl substitution in Route 2.

In Route 1 (Scheme 9), if the first step in the reaction of (RCH₂)₃Ta(Cl)ER'₃ (α-hydrogen abstraction) is rate-determining, the reaction would follow first-order kinetics. The rate constants should be the same as the rates of the decomposition of (RCH₂)₃Ta(Cl)ER'₃, and independent of the concentrations of LiER'₃. If Route 2 is the pathway to (RCH₂)₂Ta(=CHR)ER'₃, the reaction probably would not follow first-order kinetics. Thus the reactivities of (RCH₂)₃Ta(Cl)ER'₃ and kinetic studies of its decomposition and reactions with LiER'₃ would provide information regarding the formation of the alkylidene complex.

We therefore studied the kinetics of the reactions of thermally unstable $(Me_3SiCH_2)_3Ta(Cl)Si(SiMe_3)_3$. The decomposition of this purple intermediate was monitored by variable-temperature ¹H and ¹³C NMR, and was found to follow first-order kinetics. Plots of $\ln(C/C_0)$ vs t and an Eyring plot of $\ln(k_1/T)$ vs T are shown in Figs. 3 and 4, respectively, from which the activation parameters for the decomposition of $(Me_3SiCH_2)_3Ta(Cl)Si(SiMe_3)_3$ [$\Delta H_1^{\pm} = 17.2(1.0)$ kcal/mol, $\Delta S_1^{\pm} = -4.2(4.0)$ eu] could be derived. Furthermore, the reaction of $(Me_3SiCH_2)_3Ta(Cl)Si(SiMe_3)_3$ with $Li(THF)_3Si(SiMe_3)_3$ to form $(Me_3SiCH_2)_3Ta(=CHSiMe_3)Si(SiMe_3)_3$ and $HSi(SiMe_3)_3$ is kinetically identical to the decomposition of $(Me_3SiCH_2)_3Ta(Cl)Si(SiMe_3)_3$; the rates of the two reactions are the same.

We further discovered that the decomposition of (Me₃SiCH₂)₃ Ta(Cl)Si(SiMe₃)₃ led to the formation of an unstable bis(alkylidene) complex (Me₃SiCH₂)₂(Cl)₂Ta₂(=CHSiMe₃)₂ which could be regarded as the dimer of "(Me₃SiCH₂)₂Ta(=CHSiMe₃)Cl." This dimeric complex was also observed in the reaction of (Me₃SiCH₂)₃TaCl₂ with 2 equiv of Li(THF)₃Si(SiMe₃)₃. It was identified by its ¹H and ¹³C NMR and

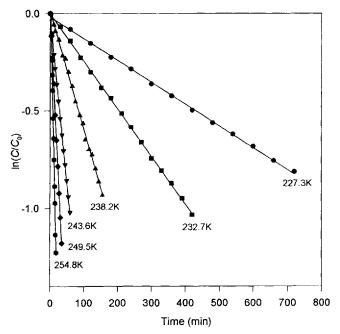


FIGURE 3 Kinetics plots of the decomposition of (Me₃SiCH₂)₃Ta(Cl)Si(SiMe₃)₃ (Ref. 16).

independently synthesized by the reaction of (Me₃SiCH₂)₄Ta₂(μ-CSiMe₃)₂ with 2 equiv of HCl (see Section 3.4 for details).

These results point to Route 1 in Scheme 9 as the pathway to the silyl alkylidene complex (Me₃SiCH₂)₂Ta(=CHSiMe₃)Si(SiMe₃)₃. The alkylidene bond Ta=CHR is formed before the Cl⁻ substitution. The intermediate "(Me₃SiCH₂)₂Ta(=CHSiMe₃)Cl" either reacts with Li(THF)₃Si(SiMe₃)₃ to form (Me₃SiCH₂)₂Ta(=CHSiMe₃)Si(SiMe₃)₃, or dimerizes to give (Me₃SiCH₂)₄(Cl)₄Ta₂(=CHSiMe₃)₂ which reacts with Li(THF)₃Si(SiMe₃)₃ to form (Me₃SiCH₂)₄Ta₂(μ-CSiMe₃)₂ (see Section 3.4 for details). This bridging bis(alkylidyne) complex was observed as a byproduct in the formation of (Me₃SiCH₂)₂Ta(=CHSiMe₃)Si(SiMe₃)₃ from the reaction of (Me₃SiCH₂)₃TaCl₂ with Li(THF)₃Si(SiMe₃)₃. Thus our results here show that the formation of the silyl alkylidene complex and the byproduct (Me₃SiCH₂)₄Ta₂(μ-CSiMe₃)₂ follow the pathways in Scheme 10.

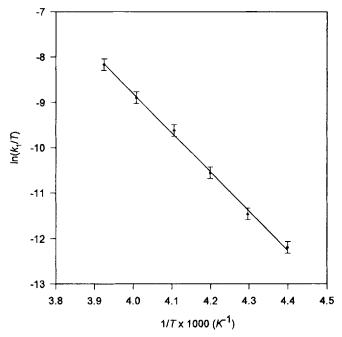


FIGURE 4 Eyring plot of the decomposition of (Me₃SiCH₂)₃Ta(Cl)Si(SiMe₃)₃ (Ref. 16).

$$(RCH_2)_3 TaCl_2 \xrightarrow{+ \text{Li}(THF)_3 SiR_3} (RCH_2)_3 Ta \xrightarrow{CI} \xrightarrow{- \text{HSiR}_3, \text{ 1st-order kinetics}} (RCH_2)_2 Ta \xrightarrow{CI} CHR$$

$$SiR_3 \xrightarrow{AH_1^+ = 17.2(1.0) \text{ kcal/mol}} (RCH_2)_2 Ta \xrightarrow{CHR}$$

$$\Delta S_1^+ = -4.2(4.0) \text{ eu}$$

$$SiR_3 \xrightarrow{- \text{HSiR}_3 = -4.2(4.0) \text{ eu}} CHR$$

$$RCH_2 \xrightarrow{- \text{CI}} CHR$$

$$(RCH_2)_4 (CI)_2 Ta_2 (= CHR)_2 \xrightarrow{- \text{Li}(THF)_3 SiR_3} RCH_2 \xrightarrow{- \text{CH}_2 RCH_2} CH_2 CH_2 RCH_2 RCH_2 CH_2 R$$

3.3 Kinetic and Mechanistic Studies of the Formation of Alkyl Alkylidene Complexes (RCH₂)₃Ta=CHR (R = CMe₃, SiMe₃) (Ref. 30)

Our pursuit of an unexpected result led us to the studies here. We soon realized the importance of these studies in demonstrating the striking differences in the reactivities of alkyl and silyl complexes.

The preparation of the first Schrock-type alkylidene complex $(Me_3CCH_2)_3Ta$ =CHCMe₃ was reported in 1974.¹⁷ The mechanistic pathways to the alkylidene complexes are not clear. Several thermally unstable pentaalkyl derivatives of tantalum, $Ta(CH_2R)_5$ (R = H, ^{31–33} Ph, ^{32,33} 4-methylbenzyl³⁴), have been reported, which decompose via α -hydrogen abstraction to give unidentified residues and methane, toluene and p-xylene, respectively.^{31–34}

As stated earlier, the bridging bis(alkylidyne) complex (Me₃SiCH₂)₄-Ta₂(μ-CSiMe₃)₂, first reported in 1973,¹⁸ was found as a byproduct in our synthesis of (Me₃SiCH₂)₂Ta(=CHSiMe₃)Si(SiMe₃)₃. In the preparation of this bridging bis(alkylidyne) compound to confirm its presence in our systems, two peaks in the ¹H and ¹³C NMR, which disappeared with time, caught our attention. Further studies confirmed that they were those of an unstable pentaalkyl intermediate Ta(CH₂SiMe₃)₅. Ta(CH₂SiMe₃)₅ was found to undergo α-hydrogen abstraction to first form a Schrock-type alkylidene complex (Me₃SiCH₂)₃Ta=CHSiMe₃, then (Me₃SiCH₂)₄Ta₂(μ-CSiMe₃)₂ as shown in Fig. 5 and Scheme 11.³⁰

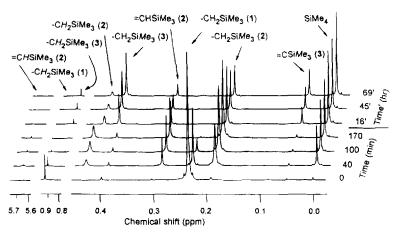


FIGURE 5 ¹H NMR (toluene- d_8) spectra of the conversions (Me₃SiCH₂)₅Ta (1) \rightarrow (Me₃SiCH₂)₃Ta=CHSiMe₃ (2) \rightarrow (Me₃SiCH₂)₄Ta₂(μ -CSiMe₃)₂ (3) (Ref. 30).

The conversion of (Me₃SiCH₂)₃Ta=CHSiMe₃ to the bridging bis(alkylidyne) complex has been reported by Schrock and Rupprecht. ^{17d,25}

The conversion Ta(CH₂SiMe₃)₅ \rightarrow (Me₃SiCH₂)₃Ta=CHSiMe₃ was observed to follow first-order kinetics with the activation parameters $\Delta H_{2}^{\neq} = 21.6(1.4)$ kcal/mol and $\Delta S_{2}^{\neq} = -5(5)$ eu.³⁰ The conversion (Me₃SiCH₂)₃Ta=CHSiMe₃ \rightarrow (Me₃SiCH₂)₄Ta₂(μ -CSiMe₃)₂ was found to follow second-order kinetics. The activation parameters for this second-order reaction are $\Delta H_{3}^{\neq} = 6.2(0.3)$ kcal/mol and $\Delta S_{3}^{\neq} = -61.6(0.8)$ eu.³⁰

Small ΔH^{\pm} and large negative ΔS^{\pm} values have been observed in associative reactions that follow second-order kinetics.³⁵ In the conversion from a monomeric (Me₃SiCH₂)₃Ta=CHSiMe₃ to a dimeric (Me₃SiCH₂)₄-Ta₂(μ -CSiMe₃)₂ discussed here, the second-order kinetics observed, the small ΔH_3^{\pm} and the unusually large negative ΔS_3^{\pm} values suggest that dimerization of (Me₃SiCH₂)₃Ta=CHSiMe₃ to an intermediate "(Me₃SiCH₂)₃Ta(μ -CHSiMe₃)₂Ta(CH₂SiMe₃)₃" is an integral part of the mechanism. This dimerization, followed by rate-determining α -hydrogen abstraction steps, constitutes one pathway, but rate-determining dimerization is more plausible in view of the characteristic activation parameters.

Ta(CH₂CMe₃)₅ was also observed as an intermediate in the reaction of (Me₃CCH₂)₃TaCl₂ with 2 equiv of LiCH₂CMe₃ to give the alkylidene complex (Me₃CCH₂)₃Ta=CHCMe₃ (Fig. 6).³⁰ (Me₃CCH₂)₄TaCl, previously reported by Schrock and Fellmann, ^{17b} was identified as an intermediate as well. The results presented here indicate the mechanistic pathway shown in Scheme 12 for the formation of the Schrock-type alkylidene complex (Me₃CCH₂)₃Ta=CHCMe₃.

In the alternate possible mechanistic pathway (Route 1, Scheme 9), a reasonable assumption is that forming "(Me₃CCH₂)₂Ta(=CHCMe₃)Cl"

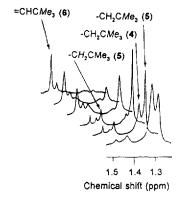


FIGURE 6 A portion of the ¹H NMR (toluene- d_8) spectra of the conversions (Me₃CCH₂)₄TaCl (4) \rightarrow Ta(CH₂CMe₃)₅ (5) \rightarrow (Me₃CCH₂)₃Ta=CHCMe₃ (6) (Ref. 30).

is the first step in the thermal decomposition of $(Me_3CCH_2)_4TaCl$, which is observed to follow first-order kinetics with $\Delta H_4^{\pm} = 6.2(0.3)$ kcal/mol and $\Delta S_4^{\pm} = -61.6(0.8)$ eu.³⁰ This thermal decomposition is found to be much slower than the reaction of $(Me_3CCH_2)_4TaCl$ with Me_3CCH_2Li . The extrapolated half-life for the decomposition of $(Me_3CCH_2)_4TaCl$ at $-40^{\circ}C$ is 1.12×10^{5} min. However, the reaction between Me_3CCH_2Li and $(Me_3CCH_2)_4TaCl$ at $-40^{\circ}C$ is virtually complete in about 80 min. The pathway involving " $(Me_3CCH_2)_2Ta(Cl)(=CHCMe_3)$ " (Route 2, Scheme 9) as the precursor to $(Me_3CCH_2)_3Ta=CHCMe_3$ is therefore unlikely.³⁶

Thus the kinetic and mechanistic studies of the formation of (Me₃SiCH₂)₂Ta(=CHSiMe₃)Si(SiMe₃)₃ show that the silyl alkylidene complex is formed by the pathway in Route 1 (Scheme 9) with the formation of the alkylidene bond preceding the Cl⁻ substitution. The formation of alkyl alkylidene complexes (RCH₂)₃Ta=CHR, on the other

$$(RCH_2)_3 TaCl_2 \xrightarrow{+ \text{LiCH}_2 R} (RCH_2)_4 TaCl \xrightarrow{+ \text{LiCH}_2 R} Ta(CH_2R)_5$$

$$(R = CMe_3)$$

$$(RCH_2)_3 Ta = CHR$$

$$(RCH_2)_3 Ta = CHR$$

$$RCH_2 \cdot H$$

$$SCHEME 12$$

hand, adopts an alternative mechanism (Route 2, Scheme 9) where the CI ligands are replaced before the formations of the alkylidene bonds. The reasons for such different reactivities are not clear. Steric factors perhaps play an important role here. The silyl ligand Si(SiMe₃)₃ is quite bulky, and may make Route 2 in Scheme 9 to "(RCH₂)₃Ta[Si(SiMe₃)₃]₂" unfavorable and Route 1 the low-energy and preferred pathway instead.

3.4 (Me₃SiCH₂)₂(Cl)₂Ta₂(=CHSiMe₃)₂ and Reaction Cycles Involving Bis(alkylidene), Nonsymmetric Bis(alkylidyne) and Symmetric Bis(alkylidyne) Complexes (Refs. 37 and 38)

The unstable bis(alkylidene) complex (Me₃SiCH₂)₂(Cl)₂Ta₂(= CHSiMe₃)₂, which is the dimer of an intermediate "(Me₃SiCH₂)₂-Ta(=CHSiMe₃)(Cl)" in the formation of (Me₃SiCH₂)₂Ta(=CHSiMe₃) Si(SiMe₃)₃, was first investigated as the product of HCl addition to the bridging bis(alkylidyne) complex (Me₃SiCH₂)₄Ta(μ-CSiMe₃)₂. Our initial interest was its reaction with Li(THF)₃Si(SiMe₃)₃. In the reaction, the unstable bis(alkylidene) complex is converted back to the bridging bis(alkylidyne) complex, through either preferential silane elimination or a direct attack of the alkylidene hydrogen atoms by Si(SiMe₃)₃. A similar reaction occurs with LiCH₂SiMe₃. Interesting reaction cycles involving symmetric bis(alkylidyne), bis(alkylidene) and nonsymmetric bis(alkylidene) complexes are shown in Scheme 13.³⁹

The addition of excess PMe₃ to the solution containing the bis(alkylicomplex for to the mixture from the reaction of (Me₃SiCH₂)₄Nb₂(μ-CSiMe₃)₂ with 2 equiv of HCl] gives stable nonsymmetric bridging bis(alkylidyne) complexes (Me₃P)₂(Cl)M(μ-CSiMe₃)₂M(Cl)(CH₂SiMe₃)₂. Interestingly the two PMe₃ molecules are both added to one metal atom in the reaction. The addition of phosphine to (Me₃SiCH₂)₄(Cl)₂Ta₂(=CHSiMe₃)₂ perhaps prompts α-hydrogen abstraction between the two Me₃SiCH₂ ligands from the same Ta atom and the α-hydrogen atoms of the alkylidene ligands, leading to the fornonsymmetric bis(alkylidyne) mation of the bridges $(Me_3P)_2(Cl)Ta(\mu-CSiMe_3)_2Ta(Cl)(CH_2SiMe_3)_2$.

The molecular structure of the Nb nonsymmetric bis(alkylidyne) complex, which is isomorphous to that of the Ta complex, is shown in Fig. 7.

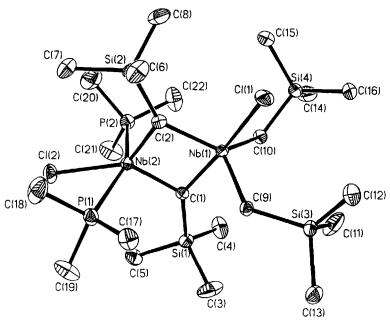


FIGURE 7 ORTEP diagram of $(Me_3P)_2ClNb(\mu-CSiMe_3)_2NbCl(CH_2SiMe_3)_2$ (Refs. 37 and 38).

The structures of the two complexes confirm the presence of nonsymmetric bis(alkylidyne) bridges. There is, to our knowledge, one other reported nonsymmetric bis(alkylidyne) complex $W_2(Me_3SiCH_2)_4(\mu-CSiMe_3)_2(\eta^2-PhC_2Me)$.

The ligands on M(2) are arranged in slightly distorted trigonal bipyramidal geometry with C(1) and C(2) at axial and equatorial positions, respectively. These two bridging alkylidyne ligands were found to be involved in unusual axial-equatorial ligand exchange processes as seen in their Me₃SiC \equiv resonances in variable-temperature ¹H and ¹³C NMR spectra. The exchange processes of the two complexes were found to have similar kinetics with the activation enthalpies and entropies $\Delta H_5^{\neq} = 13.6(0.4)$ kcal/mol and $\Delta S_5^{\neq} = -5(2)$ eu in the Ta complex, and $\Delta H_6^{\neq} = 13.0(0.3)$ kcal/mol and $\Delta S_6^{\neq} = -5(1)$ eu in the Nb complex.^{37,38} These exchanges perhaps take place through the conversion of the ground state trigonal bipyramid into a square pyramidal transition state, and back to a new trigonal bipyramidal structure. In comparison, the two axial and two of the three equatorial ligands are involved in an exchange in the Berry pseudorotation.⁴¹

The reaction of the Ta or Nb nonsymmetric bis(alkylidyne) complexes with 2 equiv of LiCH₂SiMe₃ leads to the replacement of the two chloride ligands and converts the nonsymmetric bis(alkylidyne) complexes back to (Me₃SiCH₂)₄Ta₂(μ-CSiMe₃)₂ with elimination of two PMe₃ ligands (Scheme 13). The first CH₂SiMe₃ substitution occurs at the Ta atom containing two PMe₃ ligands to form a thermally unstable intermediate (Me₃P)₂(Me₃SiCH₂)Ta(μ-CSiMe₃)₂Ta(Cl)(CH₂SiMe₃)₂. Subsequent CH₂SiMe₃ substitution of the remaining Cl⁻ ligand gives (Me₃SiCH₂)₄Ta₂(µ-CSiMe₃)₂. An interesting alkyl migration from one metal center to another might be involved in these conversions. After the first CH₂SiMe₃- substitution, subsequent CH₂SiMe₃⁻ substitution at the other Ta atom, followed by an alkyl migration, leads to the formation of (Me₃SiCH₂)₄Ta₂(μ-CSiMe₃)₂ with symmetric bis(alkylidyne) bridges. The migration of the CH₂SiMe₃ ligand in the conversions nicely completes the reaction cycles shown in Scheme 13. Alkyl migrations between metal centers have been observed in early-transition-metal complexes with direct metal-metal bonds. 42-45 However, unlike in these complexes, the rarely seen alkyl migration reported here involves two atoms that are not directly bonded.

4. CONCLUSIONS

Our studies discussed here demonstrate that early-transition-metal silyl complexes in Cp-free environments offer rich and interesting chemistry, and unusual chances to compare the reactivities of alkyl and silyl ligands. Alkyl, alkylidene and alkylidyne complexes containing silyl ligands could be prepared by substitution reactions analogous to the syntheses of alkyl, alkyl alkylidene and alkyl alkylidyne complexes. However, the silyl complexes often demonstrate reactivities different from those of corresponding alkyl compounds. More experimental and theoretical studies would help to give a better understanding of the origins of such differences and develop a more unified view of the alkyl and silyl chemistry.

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